

March 7, 2024

Description

Measurements

Carat Weight

Color Grade

Clarity Grade

Polish

Symmetry

Fluorescence

Inscription(s)

Type IIa

GRADING RESULTS

IGI Report Number

Shape and Cutting Style

ADDITIONAL GRADING INFORMATION

Comments: This Laboratory Grown Diamond was

process and may include post-growth treatment.

created by Chemical Vapor Deposition (CVD) growth

**ELECTRONIC COPY** 

LABORATORY GROWN DIAMOND REPORT

# LABORATORY GROWN DIAMOND REPORT

LG624444452 Report verification at igi.org

#### LABORATORY GROWN DIAMOND REPORT

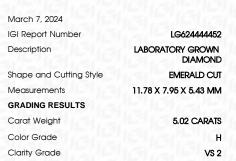
## **GRADING SCALES**

## CLARITY

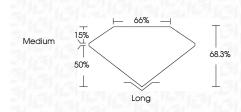
IF	VVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	l <sup>1-3</sup>
Internally	Very Very	Very	Slightly	Included
Flawless	Slightly Included	Slightly Included	Included	

## COLOR

D E F G H I J Faint Very Light	Light
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LABORATORY GROWN DIAMOND REPORT



#### ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	(157) LG624444452
Comments: This Laboratory created by Chemical Vapo process and may include p Type IIa	or Deposition (CVD) growth



EXCELLENT	NONE	1691 LG62444462	Comments: Comments: created by Chown Domond was created by Chown Corruc Deposition (CND) growth treatment. type lice	
Symmetry	Fluorescence	Inscription(s)	Comments: Comments: This Laboratory Grown and Cowfin process ( (CVD) growth tradment Type IIa	

# PROPORTIONS

LG624444452

DIAMOND

**EMERALD CUT** 

5.02 CARATS

**EXCELLENT** EXCELLENT

1/31 LG624444452

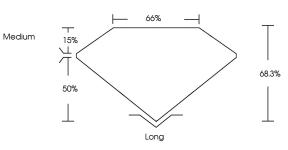
NONE

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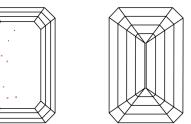
VS 2

LABORATORY GROWN

11.78 X 7.95 X 5.43 MM



## **CLARITY CHARACTERISTICS**



#### **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.



Sample Image Used







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